



162162

10 JAN 2003

58

ABSTRACT

Title of the Invention: Radiation Sensitive Composition and
Color Liquid Crystal Display Device

5

Abstract of the disclosure is:

There is provided a radiation sensitive composition which is used to form a colored layer on a substrate for driving a thin film transistor (TFT) color liquid crystal display device, the composition comprising (A) a colorant, (B) an alkali soluble resin, (C) a polyfunctional monomer and (D) a photopolymerization initiator.

There is also provided a thin film transistor (TFT) color liquid crystal display device wherein a colored layer formed on a drive substrate directly or through a passivation film is formed from the above radiation sensitive composition.

10
15



G00002